

- Drafts
- Pending
- Active
 - L1: (100210) mr or magnetoresistive or magneto-resistive or (magneto adj1 resistive)
 - L2: (8977) 1 adj1 head
 - L3: (4627) amplitude with compression
 - L4: (1063) thermal adj1 asperity
 - L5: (0) 2 same 3 same 4
 - L6: (0) 2 and 3 and 4
 - L7: (727) 1 and 4
 - L8: (49) 7 and 8 compression

• Failed.

| U | Document ID | Issue Date | Pages | Title | Current US | Current EP | ABN | Retrival | C | Inventor | S | C | P | Other |
|----|-----------------|------------|-------|--|------------|------------|-----|----------|---|-------------------------------|---|---|---|-------|
| 2 | US 20040212920 | 20041028 | 14 | Method of removing particles from an airflow and a data storage device | 360/97.02 | | | | | Tadepalli, Srinivas et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 3 | US 20040085670 | 20040506 | 1 | Method for measuring pad wear of padded slider with | 360/75 | 360/31 | | | | Li, Xinwei et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 4 | US 20020159175 | 20021031 | 1 | Method of reading magnetic information which is | 360/25 | | | | | De Jong, Gerben Willem et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 5 | US 20020119346 | 20020829 | 1 | Magnetic recording medium | 428/694BS | | | | | Naoe, Koji et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 6 | US 20010055935 | 20011227 | 1 | Polishing method, polishing device, glass substrate for | 451/35 | 451/104; | | | | Miyamoto, Takemi | Γ | Γ | Γ | ΓΓΓΓΓ |
| 7 | US 20010039810 | 20011115 | 1 | Process for producing glass substrate for information | 65/30.14 | 65/30.13; | | | | Eda, Shinji et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 8 | US 6700727 B1 | 20040302 | 1 | Slider and method for actively controlling crown | 360/75 | 360/236.1; | | | | Crane, Peter et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 9 | US 6641465 B2 | 20031104 | 1 | Polishing method, polishing device, glass substrate for | 451/104 | 451/106; | | | | Miyamoto, Takemi | Γ | Γ | Γ | ΓΓΓΓΓ |
| 10 | US 6534168 B2 | 20030318 | 1 | Magnetic recording medium comprising a lower layer | 428/329 | 428/694BS; | | | | Naoe, Koji et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 11 | US 6534120 B1 | 20030318 | 1 | Chemically reinforced glass manufacture method, | 427/127 | 427/402; | | | | Osawa, Jun et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 12 | US 6525909 B1 | 20030225 | 1 | Disc head slider having deeply recessed corners | 360/235.7 | | | | | Qian, Weimin et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 13 | US 6475599 B1 | 20021105 | 1 | Substrate for information recording media | 428/141 | 360/135; | | | | Saito, Yasuhiro et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 14 | US 6430965 B1 | 20020813 | 1 | Process for producing glass substrate for information | 65/30.14 | 134/2; | | | | Eda, Shinji et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 15 | US 6427469 B1 | 20020806 | 1 | Process for producing glass substrate for information | 65/30.14 | 65/374.12; | | | | Eda, Shinji et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 16 | US 6332338 B1 | 20011225 | 1 | Method of producing glass substrate for information | 65/29.21 | 65/30.14; | | | | Hashimoto, Kazuaki et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 17 | US 6280294 B1 | 20010828 | 1 | Polishing method, polishing device, glass substrate for | 451/34 | 451/103; | | | | Miyamoto, Takemi | Γ | Γ | Γ | ΓΓΓΓΓ |
| 18 | US 6196062 B1 | 20010305 | 1 | Trailing edge acoustic emission sensor and | 73/105 | 324/210 | | | | Wright, John Stuart et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| 19 | WO 2001050462 A | 20010712 | 1 | Process for producing glass substrate for information | 65/30.14 | 65/60.5; | | | | Takahashi, Koji et al. | Γ | Γ | Γ | ΓΓΓΓΓ |
| | | | | Magnetic information reading | | 65/60.53; | | | | DE JONG, G. B. et al. | Γ | Γ | Γ | ΓΓΓΓΓ |

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